

*Real & k- space imaging of electronic states
in Na-doped $\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$*

Hide TAKAGI (University of Tokyo & CERC & RIKEN)

With Y.Kohsaka, T.Hanaguri & T.Sasagawa (Tokyo)

F.Ronning, K.Shen & Z.X.Shen (Stanford)

M.Azuma & M.Takano (Kyoto)

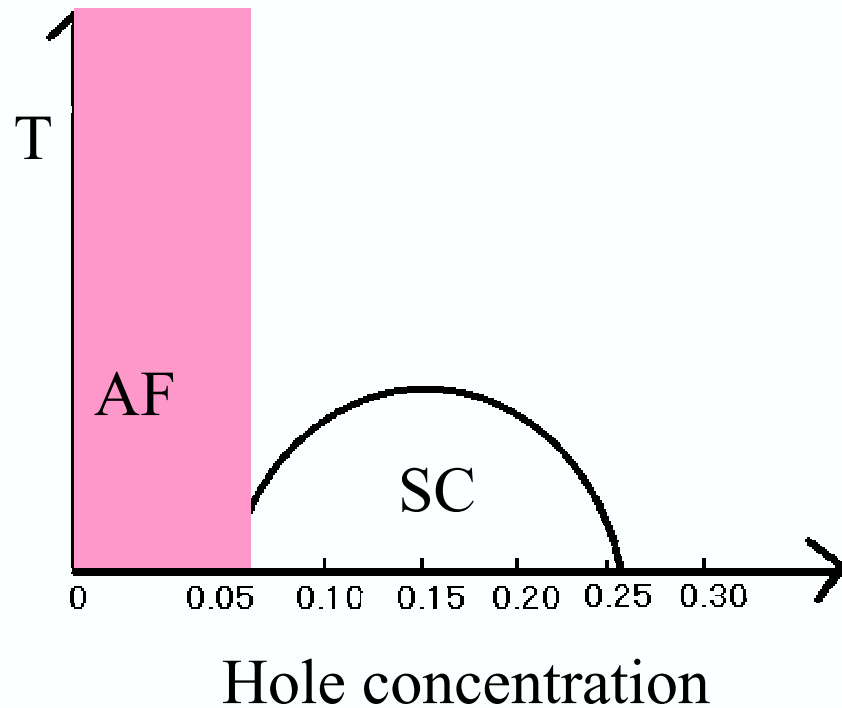
OUTLINE

1. *Motivation & Why $\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$*
2. *Crystal Growth*
3. *Basic Properties - transport, optics & ARPES*
4. *ARPES observation of the chemical potential shift from Mott Insulator to lightly doped insulator*
5. *STM/STS observation of nano-scale electronic inhomogeneity in lightly doped CuO_2 plane organized structure $\sim 5a$ width river "Kishimen"*
6. *discussion*

Motivation

– Physics of lightly doped Cuprate

evolution of magnetic insulator into high- T_c SC upon carrier doping



- How FS develops?
- link between d-wave Mott gap, pseudo gap and SC gap?
- Intrinsic Electronic inhomogeneity? (electronic phase separation, poorly screened impurity) Stripe?

!

Real space/k-space imaging of electronic structure by STM/STS & ARPES (in the lightly doped region)

Surface sensitive technique & require high quality of surface

BSCCO chemically unstable near T_c .

- Need for New System

M²S 2000 Conference summary

Materials & Properties

Hidehori TAKAGI

Department of Advanced Materials Science, University of Tokyo, 7-3-1 Hongo, Tokyo 113

Bi cuprates:

*favorites of
STM/ARPES people,
because of the easy
cleavage*

*but not stable when
heavily underdoped*

surfaces. We should pay more attention to developing materials suitable for such surface sensitive experiments. This is particularly true for the heavily underdoped region, where high-quality Bi single crystals are hard to come by. The exploration of the heavily underdoped region becomes increasingly important to establish the connection between the parent Mott insulator and the key features outlined above.

Why $(\text{Ca,Na})_2\text{CuO}_2\text{Cl}_2$?

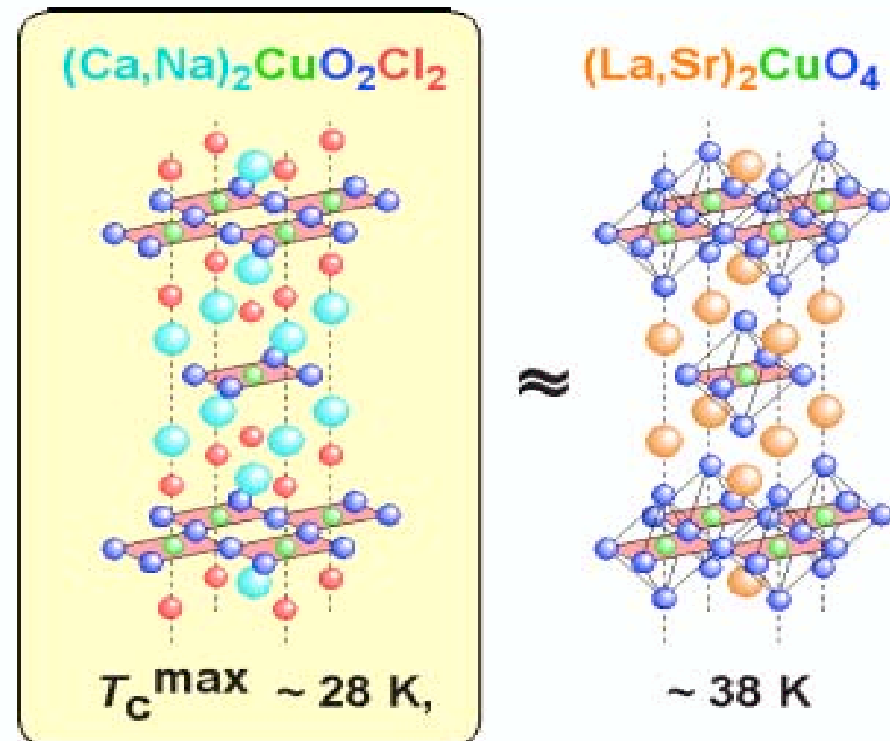
- *Excellent cleave*
only Bi and oxychloride
- *No modulation,*
tetragonal down to low-T
Undistorted CuO_2 monolayer

ideal candidate for STM & ARPES studies

- *Phase exists from Ins. to UD SC*

Hole-doping achieved by Na^+
substitution for Ca^{2+}

Z. Hiroi *et al.*, Nature **371**, 139 (1994).



	Cleave	Doping State		
		Insulator	SC	Metal
LSCO	$\triangle$			
BSCCO	$\odot$			
NaCCOC	$\odot$			

Parent compound $\text{Ca}_2\text{CuO}_2\text{Cl}_2$ ••A
ARPES Ins. standard

F.Ronning, Z.X.Shen *et al.* Science 282, 2067 (98)

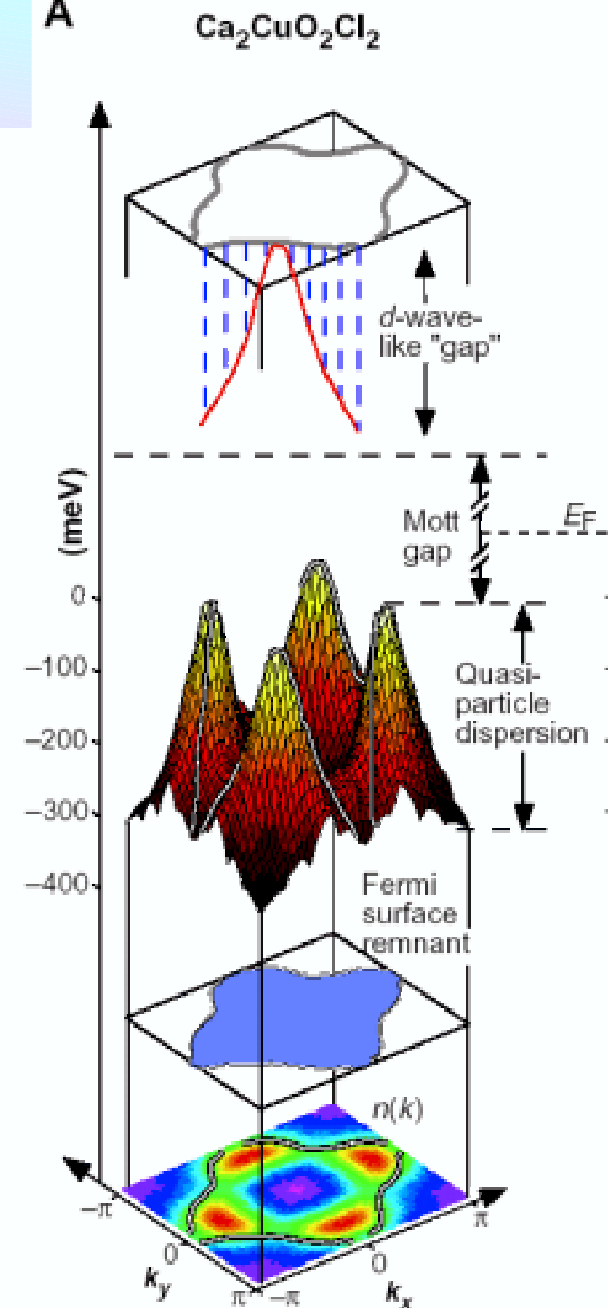
Mott gap with d-wave like dispersion



Evolution of d-wave Mott Ins into SC?

*Bad news: Na-doped phase formed only under
High Pressure*

*Na-doping requires high pressure
synthesis under several GPa & No
doped single crystal available*

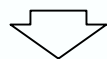


Single Crystal Growth under High Pressure

with Azuma & Takano

Specially designed
Cubic-Anvil type HP apparatus

☆ Pt capsule { Diameter: 9.6 mm
height: 15 mm

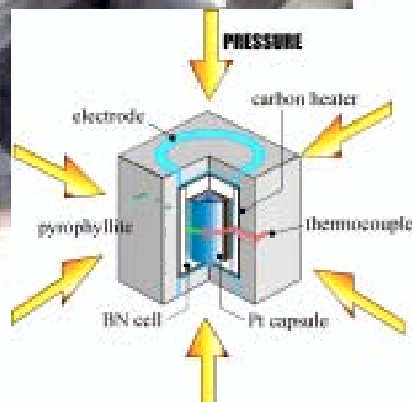
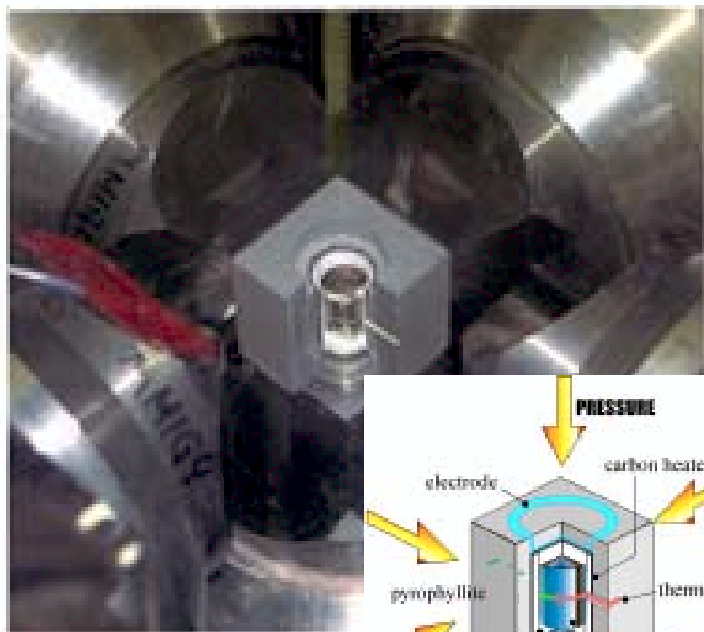


5.5 GPa in volume ~ 1 cm³

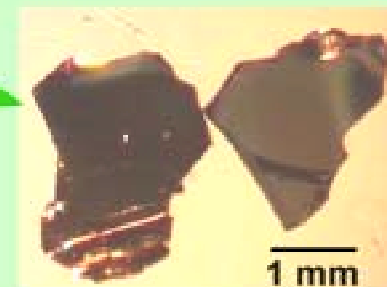
Ca₂CuO₂Cl₂ Powder
NaCl (flux, Na source)
NaClO₄ (O₂ & Na source)



2 ~ 5.5 GPa
1230 ~ 970°C / 30 hrs



(Ca,Na)₂CuO₂Cl₂ Crystals



recent success includes *PrNiO*₃ a high valence compound

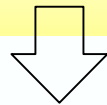
Chemistry - control of Na content

(a) $\text{Ca}_2\text{CuO}_2\text{Cl}_2 + 0.2\text{NaClO}_4 + 0.2\text{NaCl}$

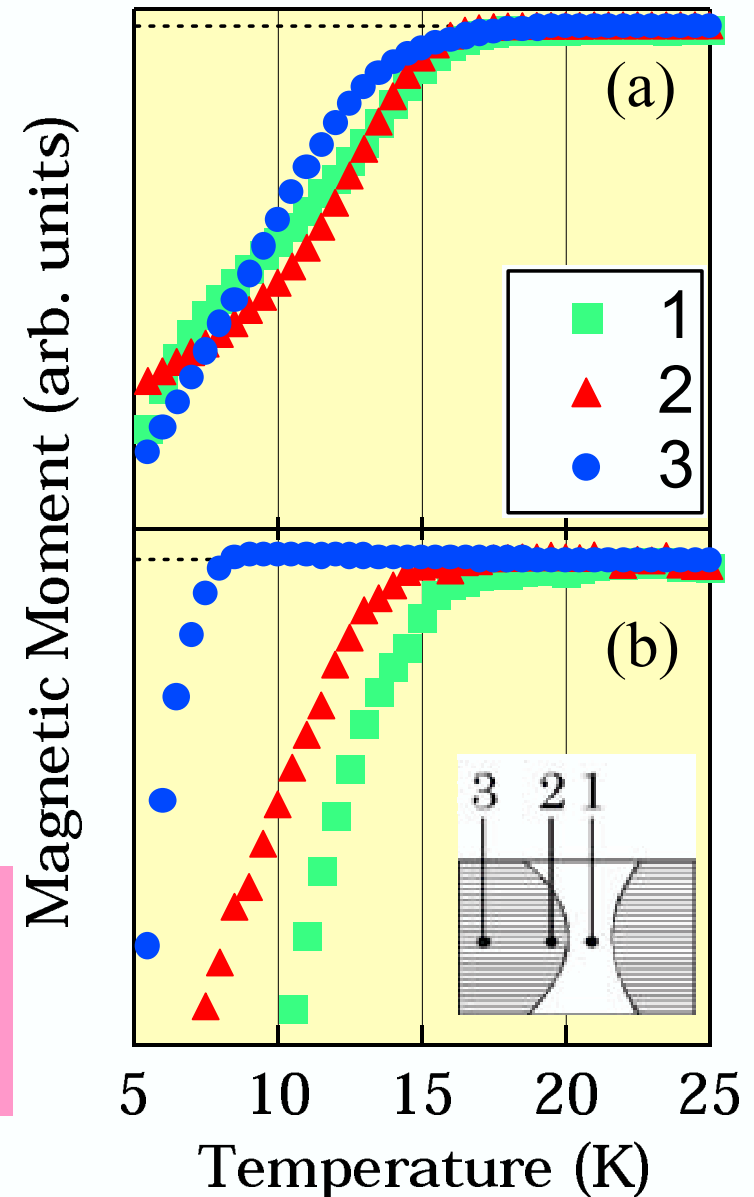
(b) $\text{Ca}_2\text{CuO}_2\text{Cl}_2 + 0.2\text{NaClO}_4$

4GPa, 1230-1050°C / 30hrs

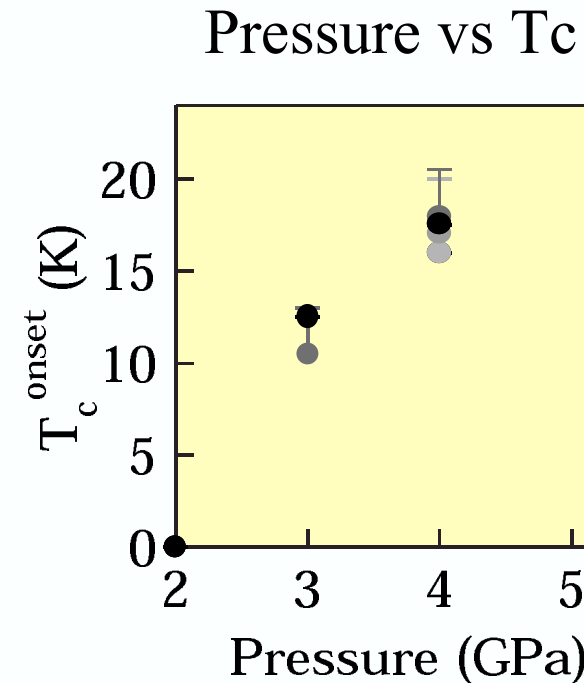
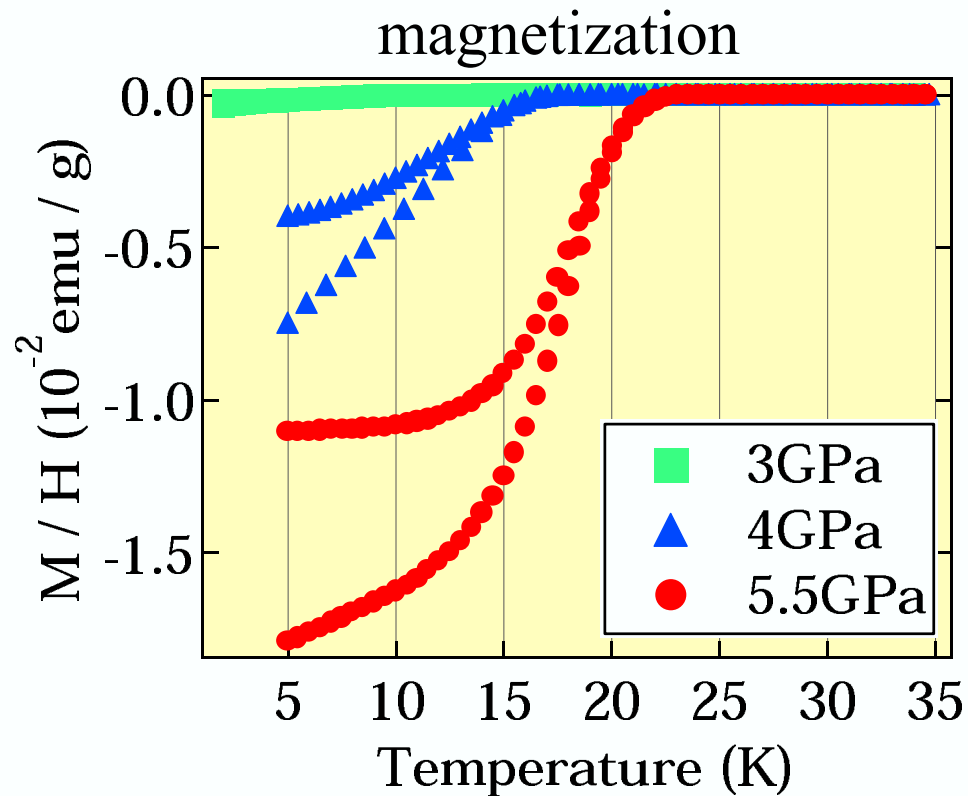
(b) Na content x changes from place to place



(a) *substantially excess Na
more homogeneous
because the solubility limit determines x*



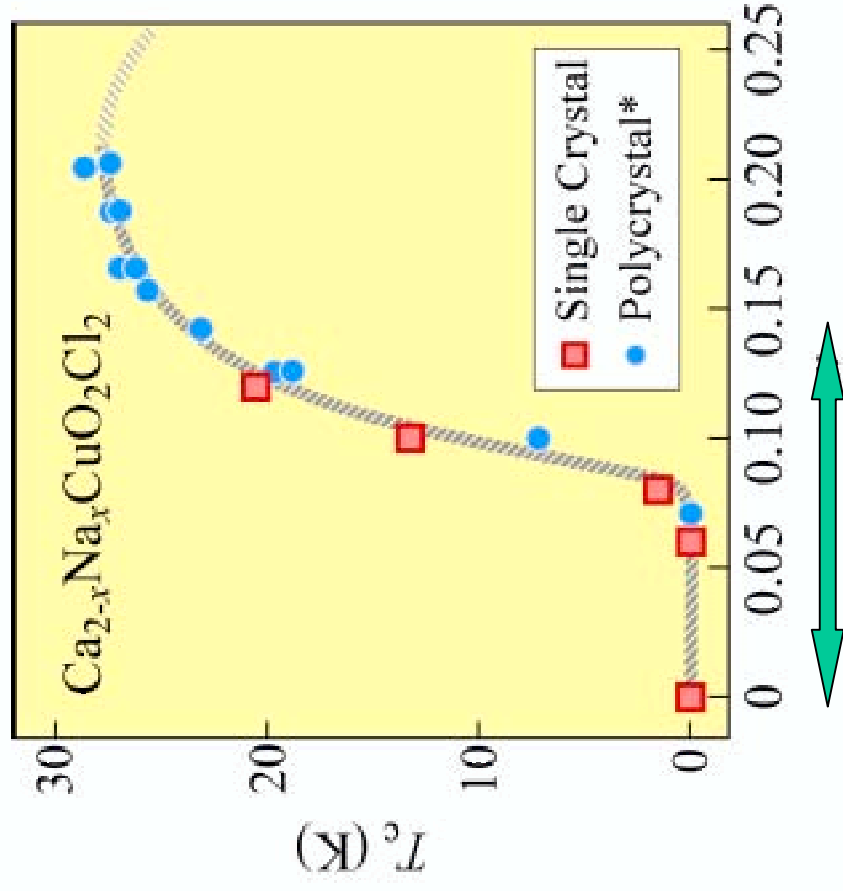
Pressure control of Na content



*Na content can be controlled by P through solubility limit
→ by far more homogeneous*

Phase Diagram of

$\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$ Single Crystals



-Evolution of d-wave
Mott gap

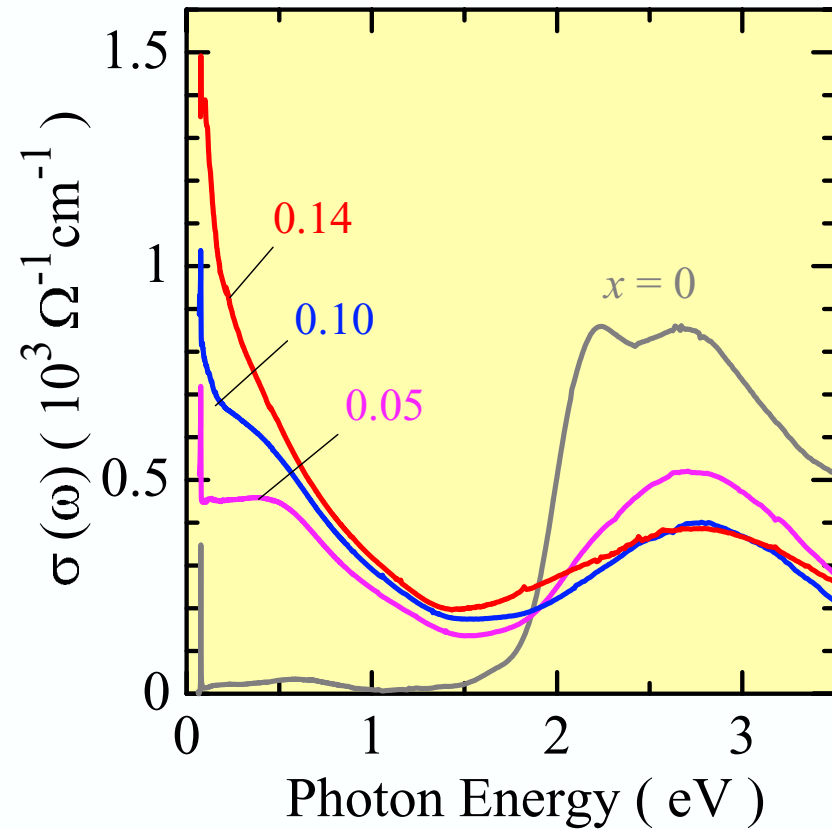
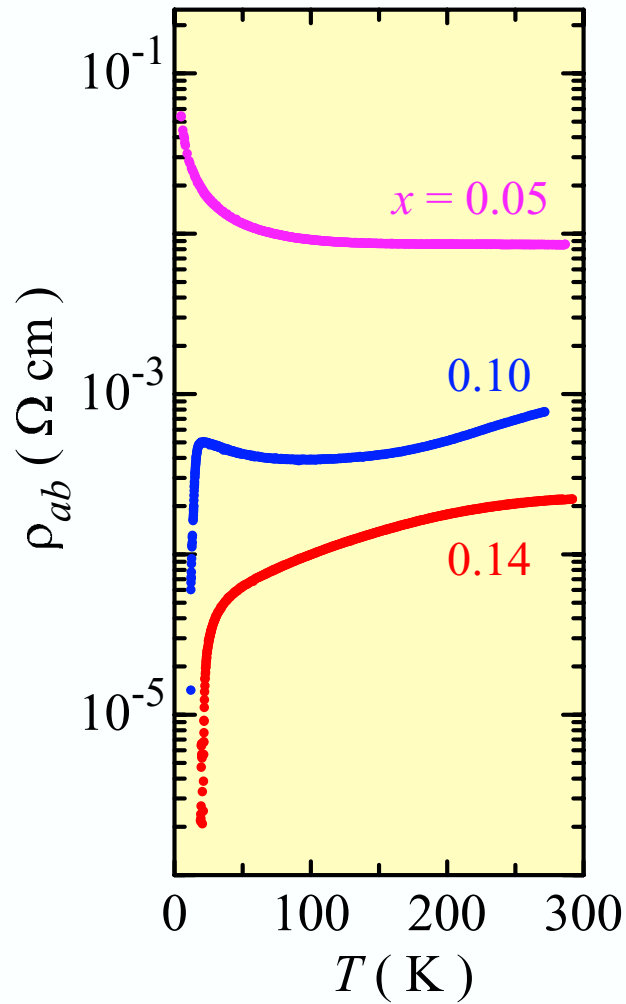
ARPES with Shen G

- Real space imaging
of possible electronic
phase separation

STM

Single crystal available from $x=0$
to 0.14

Resistivity & Optical conductivity



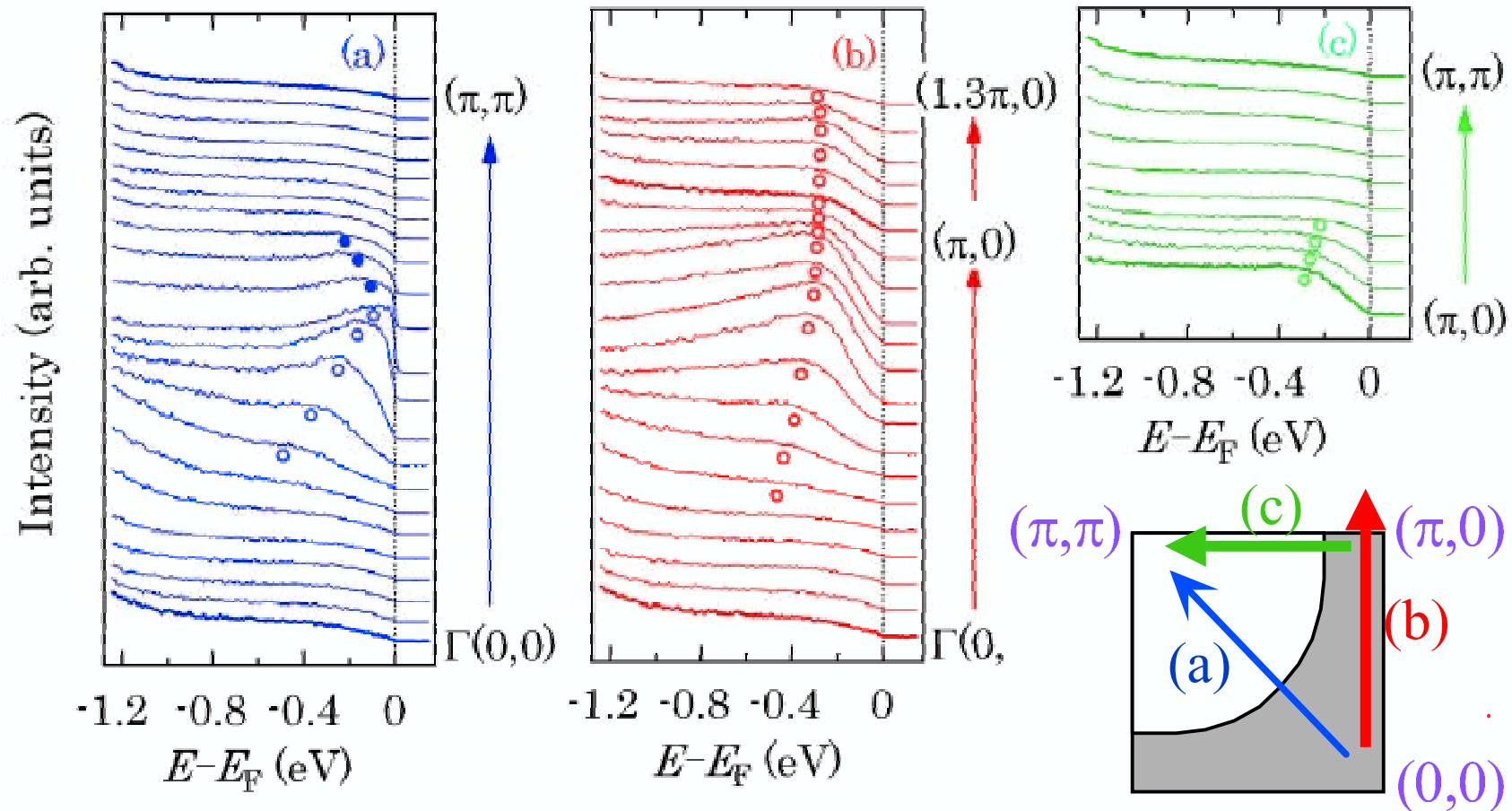
M-I (likely S-I) transition at $x=0.05-0.1$

ARPES on $\text{Ca}_{1.9}\text{Na}_{0.1}\text{CuO}_2\text{Cl}_2$ single crystal

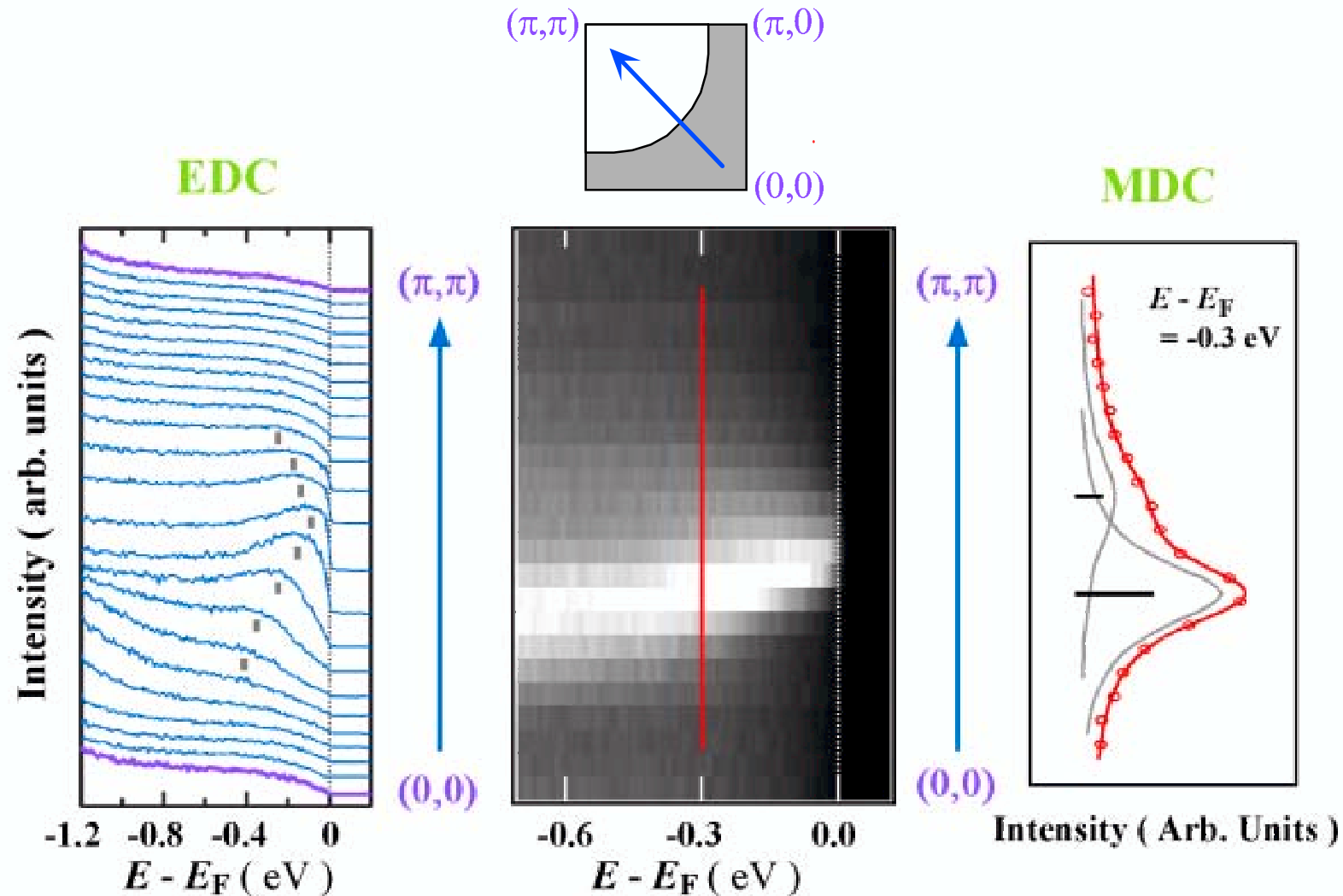
*shadow band
around $(\pi/2, \pi/2)$*

*Suppression of weight
around $(\pi, 0)$*

*extremely large pseudogap
0.1-0.2 eV!*



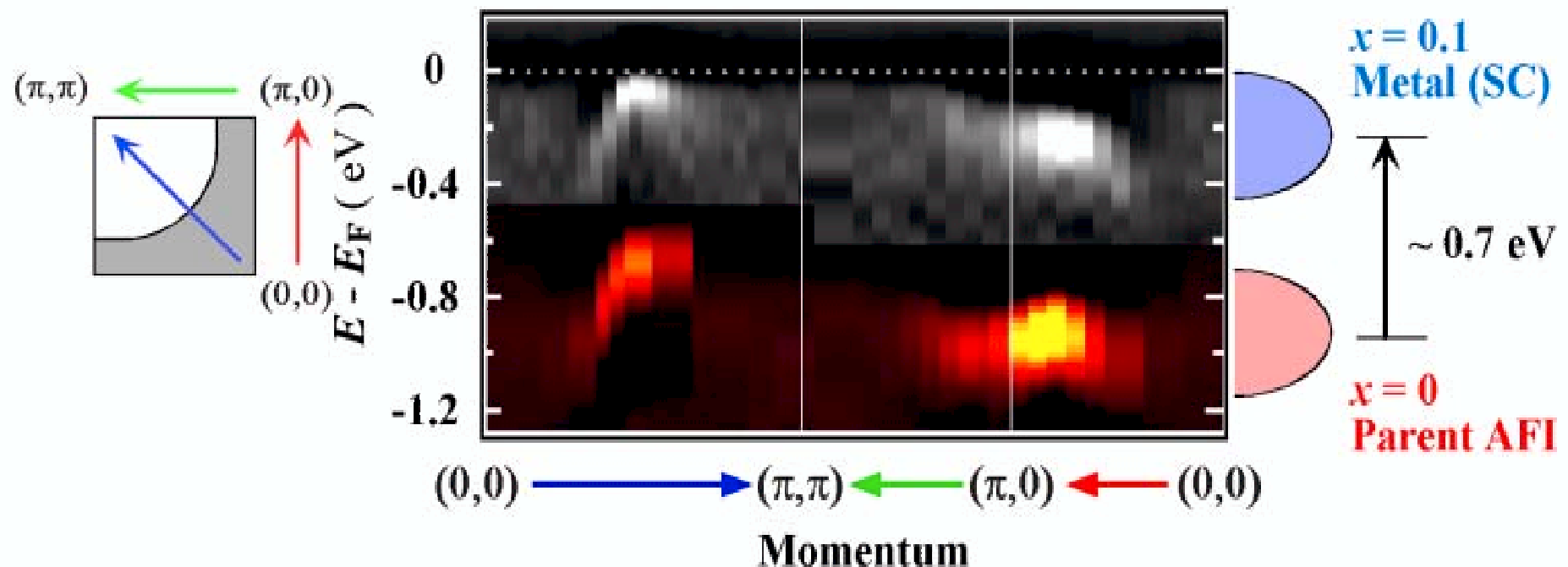
ARPES Spectra along $(0,0)$ to (π,π)



Fermi Surface Crossing around $(\pi/2, \pi/2)$
Dispersion Pulling Back after FS-Crossing -- "Shadow Band"

Electronic evolution from AFI to SC in $\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$ "Chemical Potential Shift"

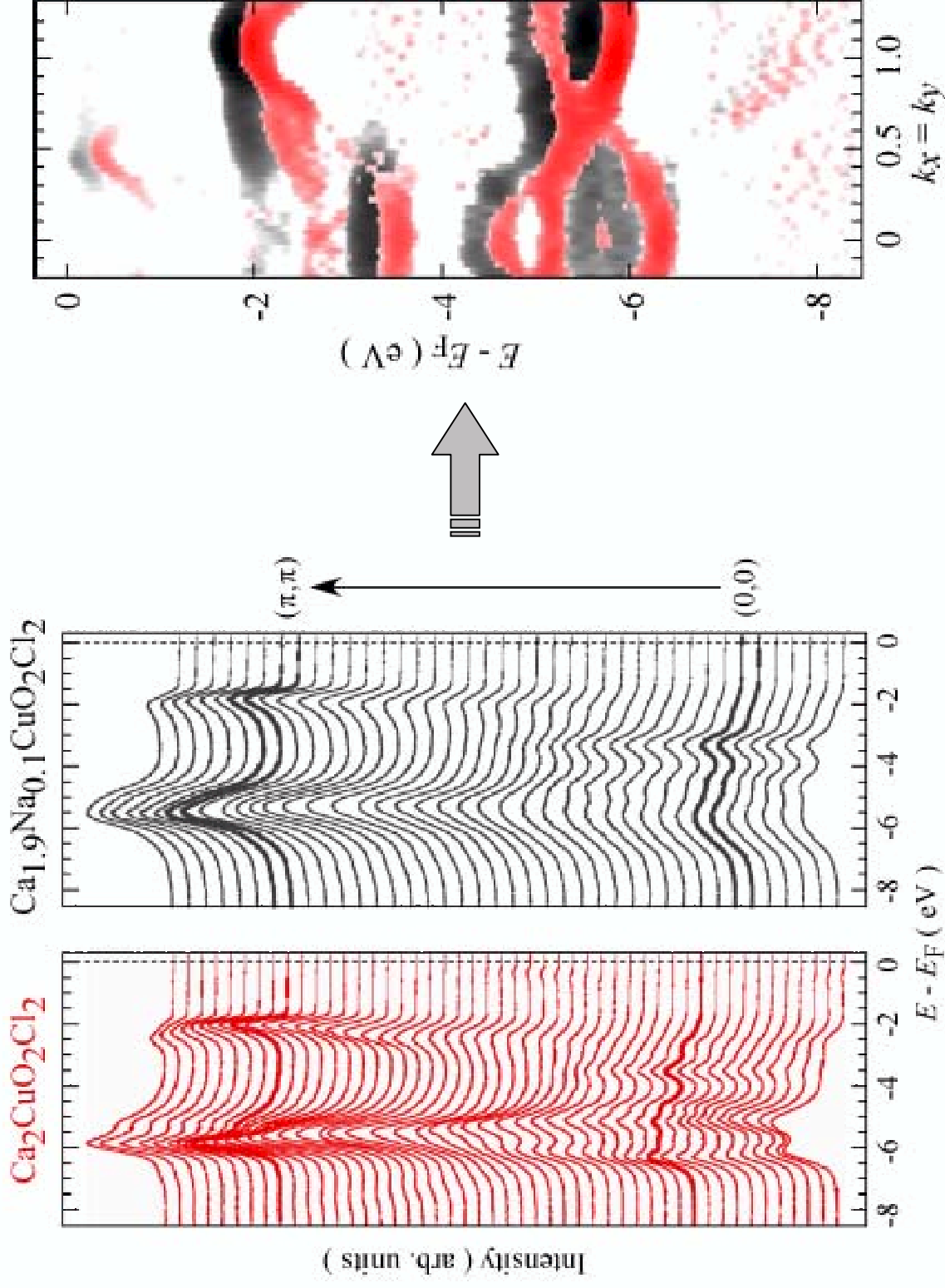
ARPES With Z.X.Shen (Stanford)



Fingerprints of the parent AFI

- (1) Shadow Band near $(\pi/2, \pi/2)$
- (2) Large Pseudo Gap around $(\pi, 0)$

Valence Band Dispersion



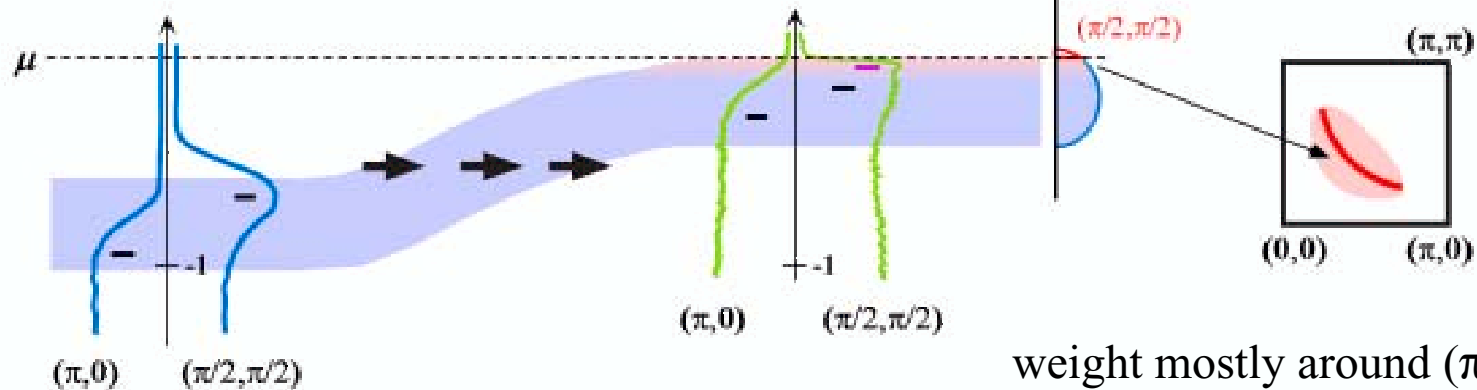
Electronic Evolution from AFI to SC

– contrast between $\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$ & $\text{La}_{2-x}\text{Sr}_x\text{CuO}_4$

Real Space Imaging?

$\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$

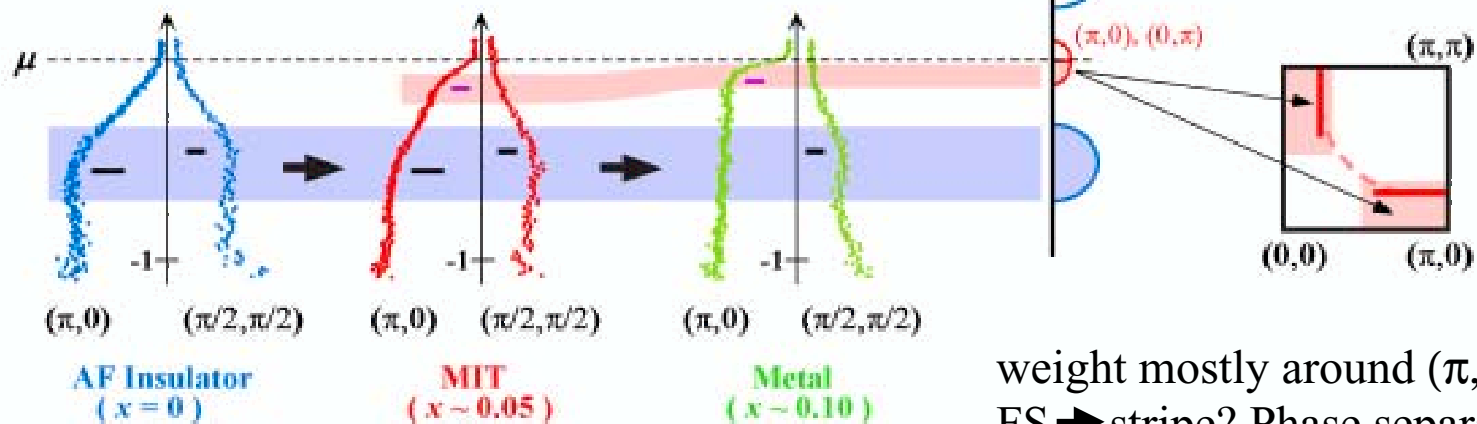
Chemical potential shift



weight mostly around $(\pi/2, \pi/2)$

$\text{La}_{2-x}\text{Sr}_x\text{CuO}_4$

Two components



weight mostly around $(\pi, 0)$ 1D
FS $\rightarrow$ stripe? Phase separation?

New STM installed at Tokyo

Ultra high vacuum

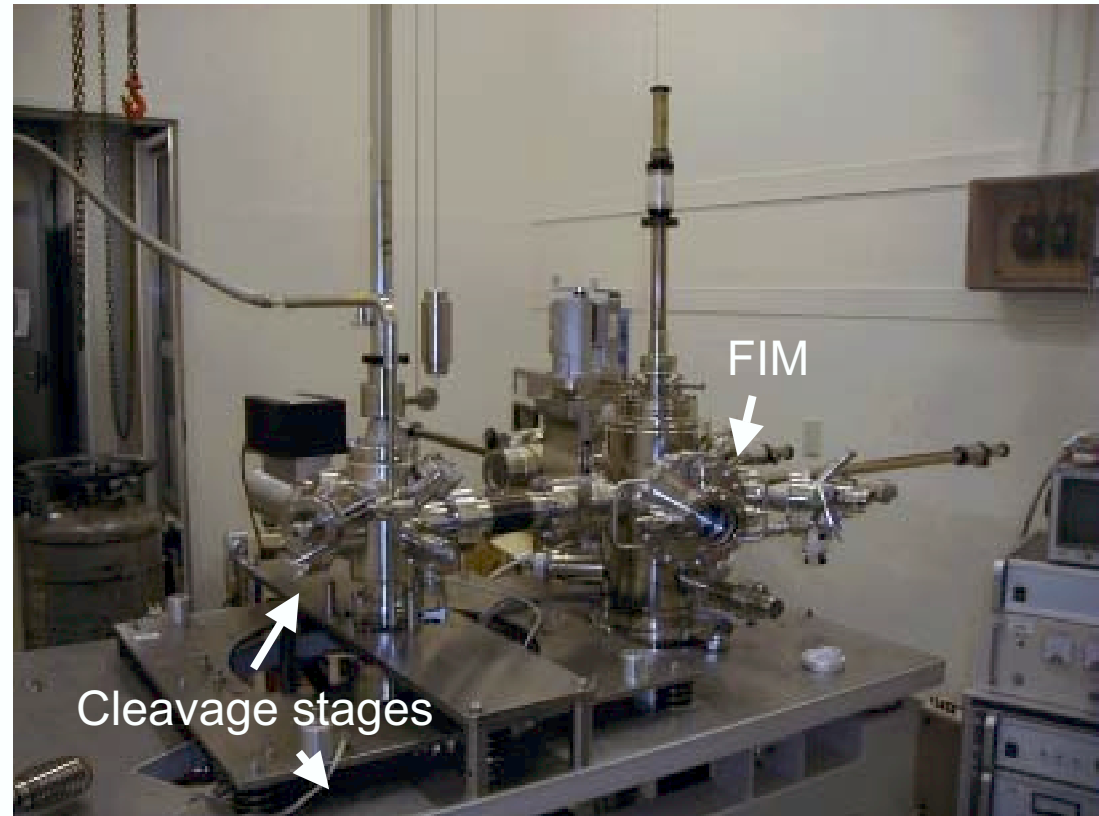
$P \sim 10^{-11}$ Torr)

Low temperature

$T \sim 0.3$ K)

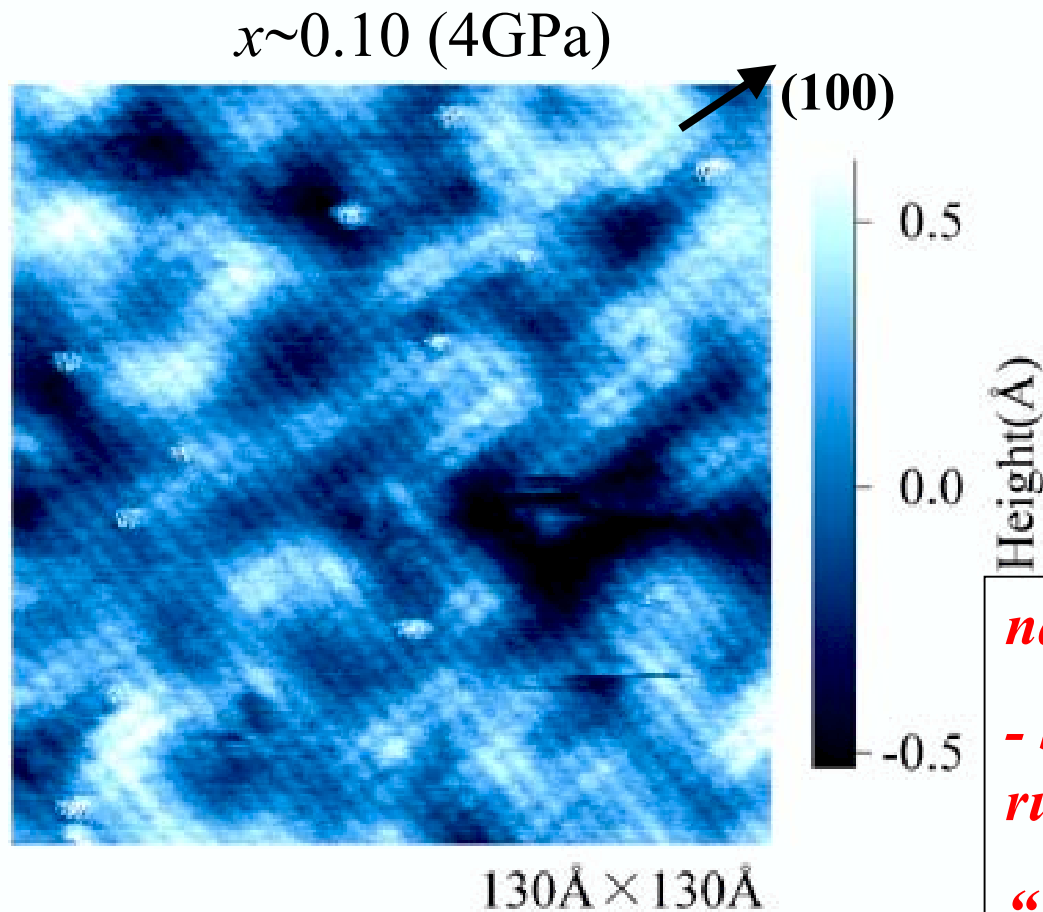
High magnetic field

$H \sim 11$ T)



- *Low-temperature cleavage stages*
- *In-situ tip preparation using a field-ion microscope*

The first STM image of $\text{Ca}_{1.9}\text{Na}_{0.1}\text{CuO}_2\text{Cl}_2$



-low temperature cleave, the same as ARPES, should have surface of similar quality

-atomic image observed from the first attempt

-square lattice with 3.9Å spacing, ionic CaCl layer

nano-scale (organized) structure

- bright river with 5a width are running along (100)

“Kishimen” (Japanese fettuccine)

not a terrace but electronic

$P \sim 10^{-11}$ torr

$T = 14\text{K}$ Sample bias : -100mV

$I_t \sim 0.05\text{nA}$ constant current

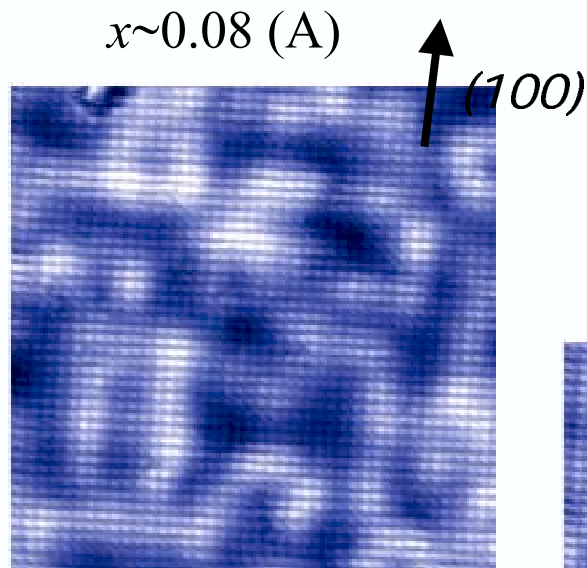
*"Kishimen" like segments
running along (100) with
~5 a (2nm) width*

STM Images of $\text{Ca}_{1.92}\text{Na}_{0.08}\text{CuO}_2\text{Cl}_2$ (not SC)

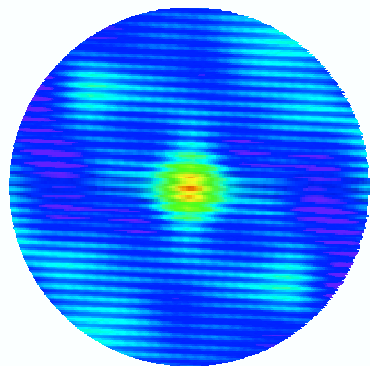
$P \sim 10^{-11}\text{Torr}$, $T = 7\text{K}$

Sample bias voltage: $V_s = -250\text{mV}$

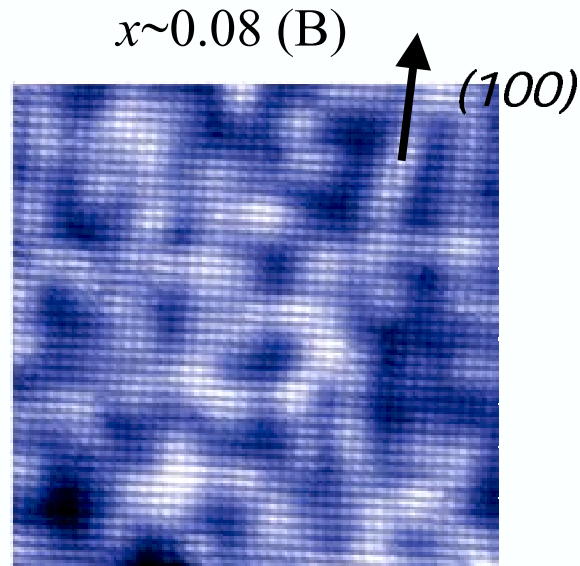
Tunneling current: $I_t \sim 0.01\text{nA}$



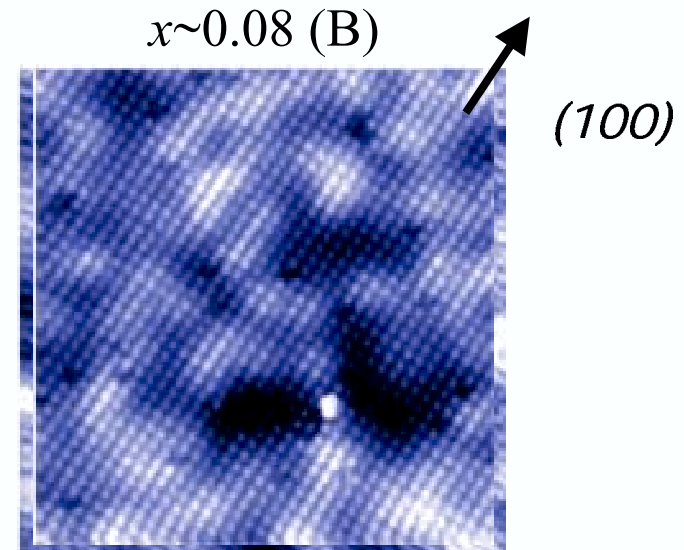
160 Å



Auto-Correlation



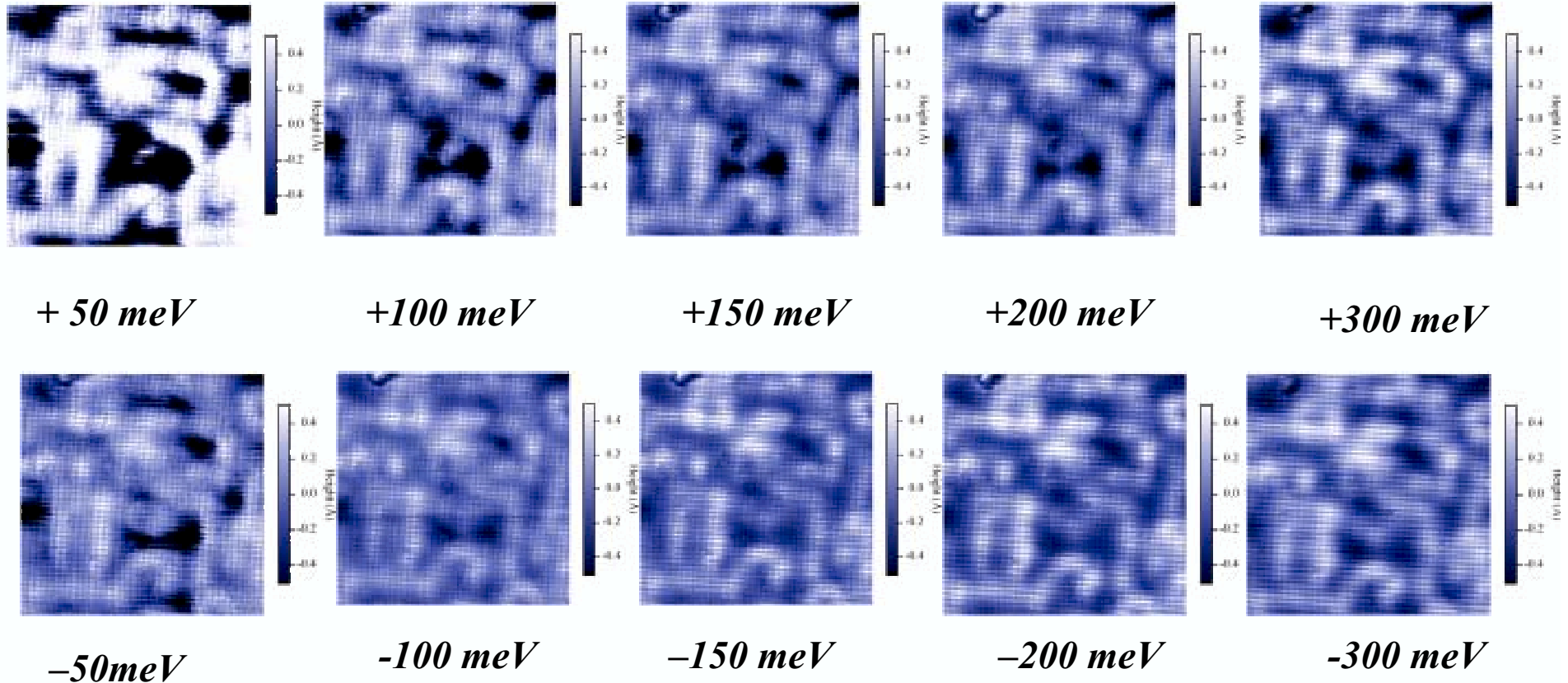
160 Å



150 Å

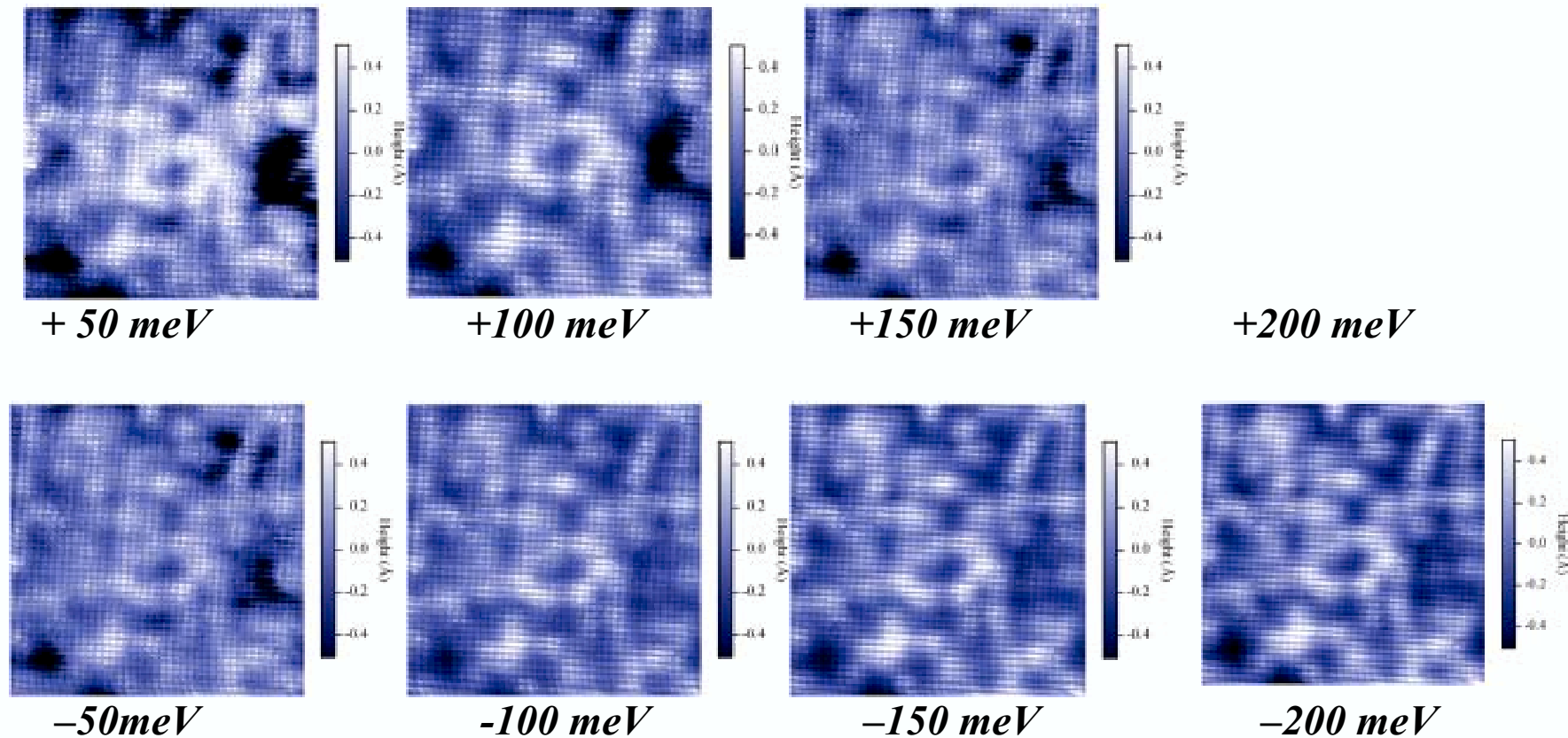
The nano-scale structure well defined & distinct

The position & shape of bright and dark segments does not depend on the bias voltage



**Bias voltage dependence of
STM image on $\text{Ca}_{1.92}\text{Na}_{0.08}\text{CuO}_2\text{Cl}_2$**

"Enhanced" Contrast at "positive" and "low" bias voltages



Bias voltage dependence of STM image on $\text{Ca}_{1.92}\text{Na}_{0.08}\text{CuO}_2\text{Cl}_2$

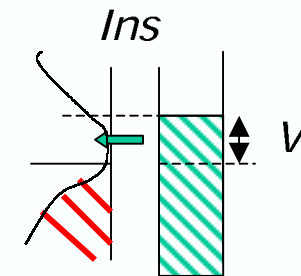
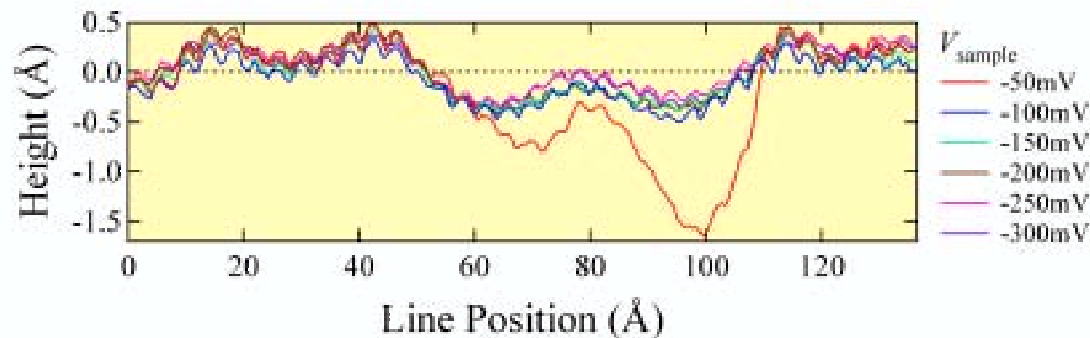
Two regions – different in low energy (100 meV) empty states (dark region gapped)

Empty state

The contrast represents the difference in integrated DOS up to the bias voltage

$$I_t \propto \int N(E) dE$$

Filled state

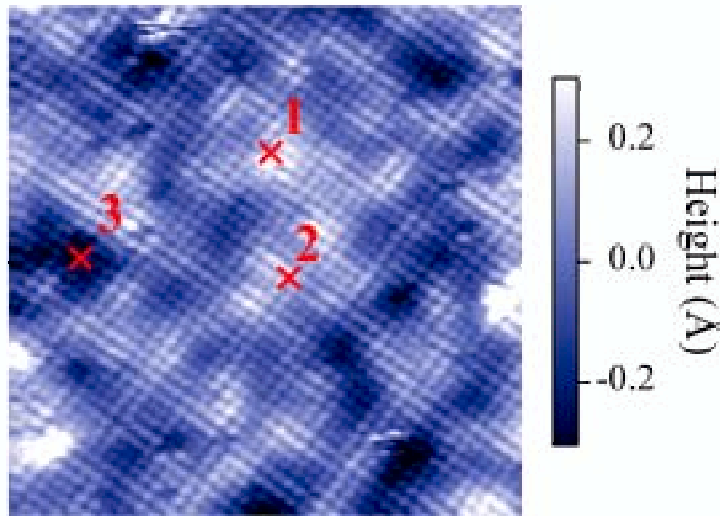
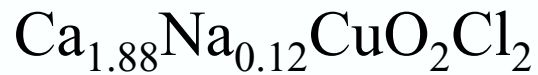


positive bias



empty states

Contrast in Differential Tunneling Conductance

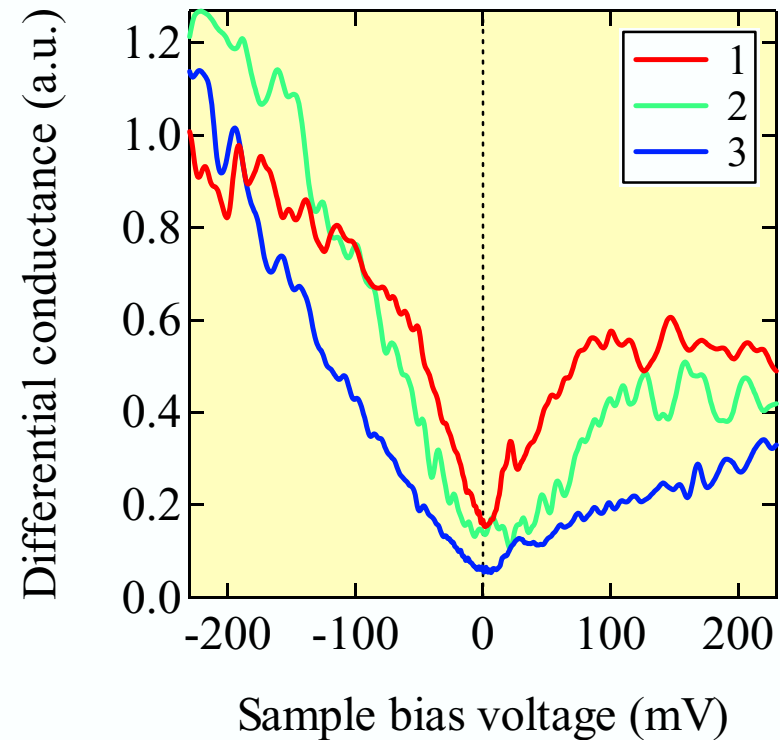


$T = 7\text{K}$

$V_{\text{sample}} = -150\text{mV}$

$I_t \sim 50\text{pA}$

Normalized spectra



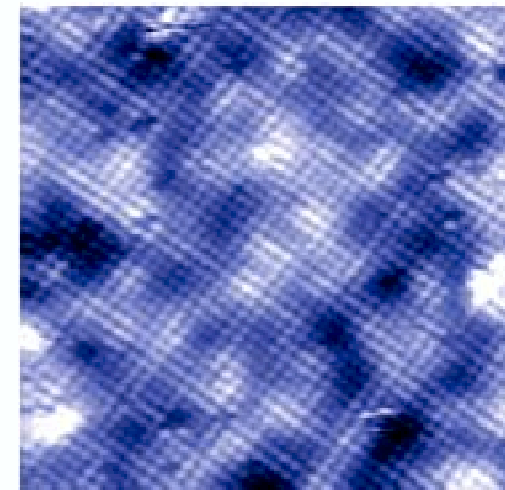
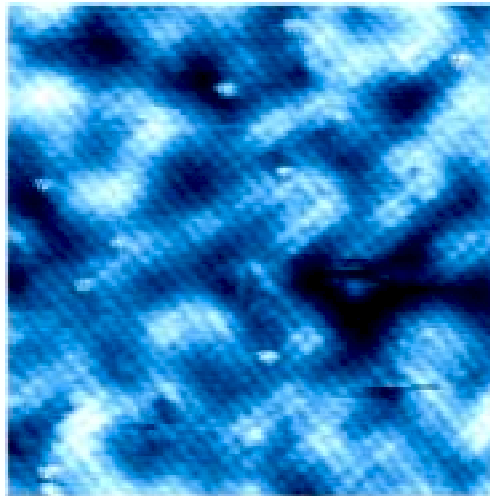
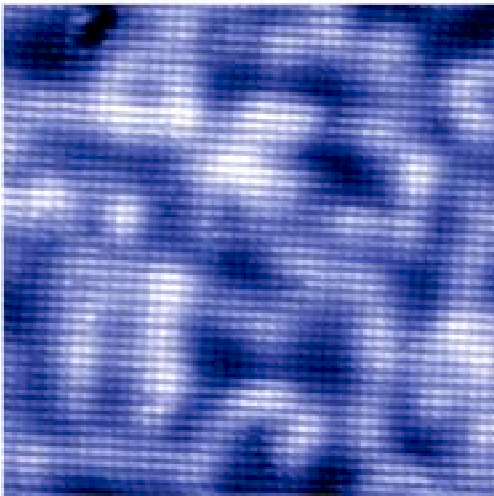
Bright segment more metallic with larger low energy DOS

*STM image of $\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$
– evolution upon doping*

$x \sim 0.08$ (3GPa, $T_c = 0\text{K}$)

$x \sim 0.10$ (4GPa, $T_c = 12\text{K}$)

$x \sim 0.12$ (5.5GPa, $T_c = 21\text{K}$)



$T = 7\text{K}$
Sample bias : -250mV
 $I_t \sim 0.01\text{nA}$

$T = 14\text{K}$
Sample bias : -100mV
 $I_t \sim 0.05\text{nA}$

$T = 7\text{K}$
Sample bias : -300mV
 $I_t \sim 0.4\text{nA}$

STM image of Lightly doped oxychloride (Ca,Na)₂CuO₂Cl₂

Definite two regions with different electronic states : metallic Kishimen-like region (bright) & the remaining less metallic region (dark)

- $5a$ (2 nm) in width
- in many cases running along (100) [$10-20 a$ (5nm) in length]
- Two phases different in 0.05-0.1 eV scale electronic structure

-different from much discussed “stripe”

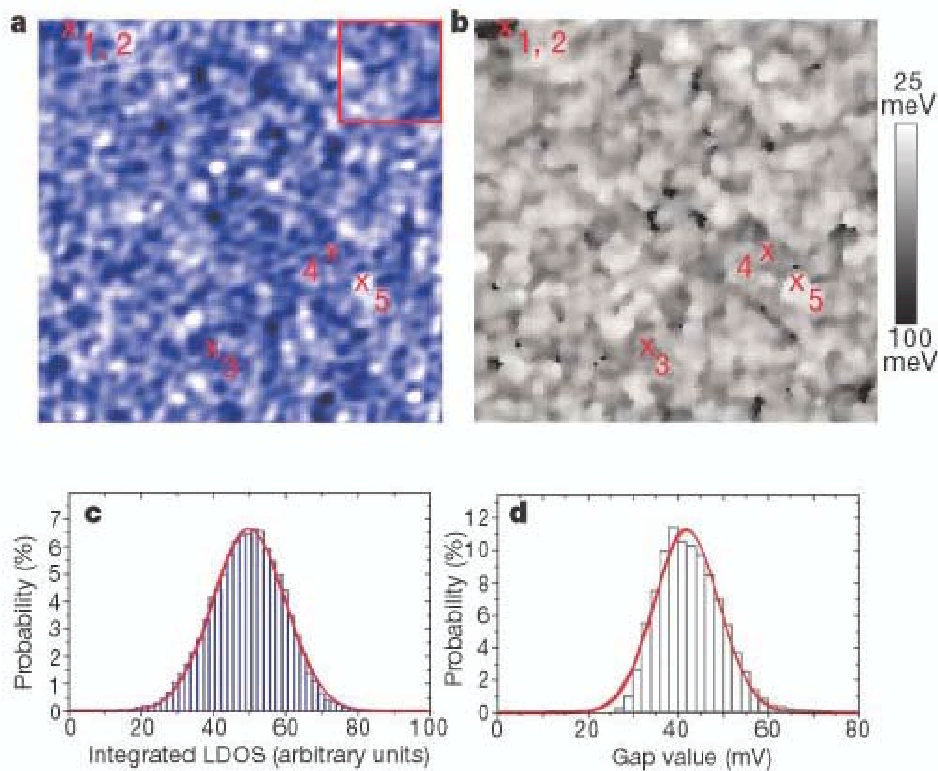
Metallic region much wider (1a width metallic river for every 4a)

- Any link with SC Inhomogeneity observed in BSCCO by Berkely G?

-Consistent with ARPES?

Microscopic electronic inhomogeneity in the high- T_c superconductor $\text{Bi}_2\text{Sr}_2\text{CaCu}_2\text{O}_{8+x}$

S. H. PAN*, J. P. O'NEAL*, R. L. BADZEY*, C. CHAMON*, H. DING†, J. R. ENGELBRECHT†, Z. WANG†, H. EISAKI‡ §, S. UCHIDA‡, A. K. GUPTA , K.-W. NG , E. W. HUDSON ¶ §, K. M. LANG ¶ & J. C. DAVIS ¶



Oxychloride

- lightly doped close to Mott insulator

- Normal state

||

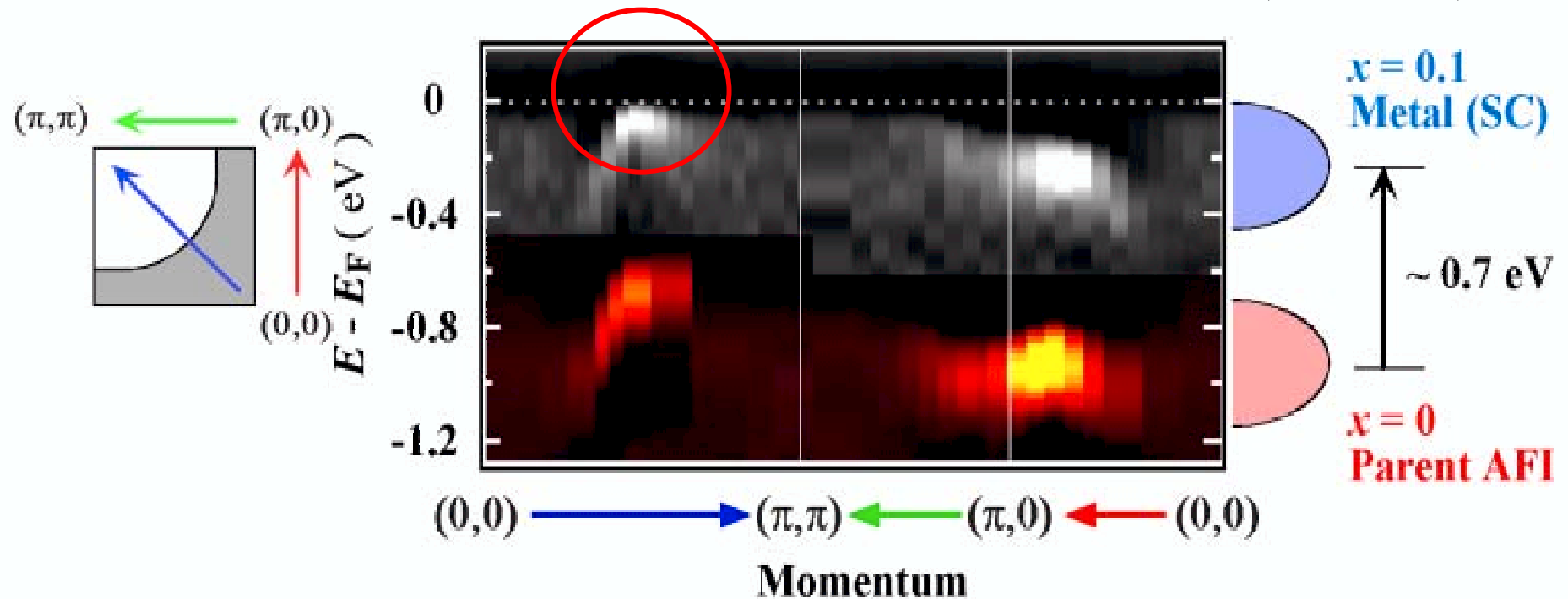
- ***Distinct two regions*** rather than inhomogeneous distribution

- ***Organized structure***

more like “phase separation”

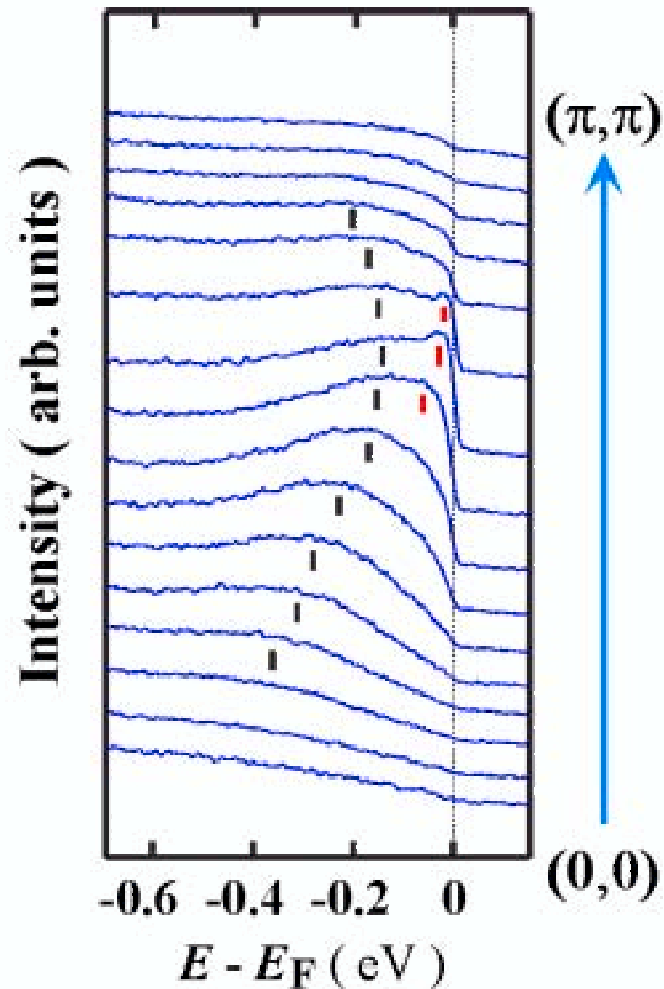
Signature of inhomogeneity seen in ARPES?

ARPES With Z.X.Shen (Stanford)

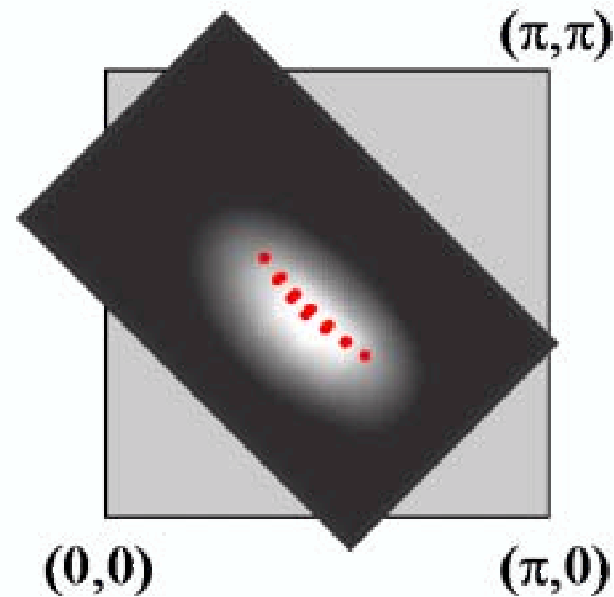


Energy scale too small ??

Low energy two component feature observed in ARPES around $(\pi/2, \pi/2)$



Intensity map (100 meV window)



• *coherent peak observed*

$\rightarrow$ *Fermi surface arc*

Broad (incoherent) bump

$\rightarrow$ *shadow band*

Origin of the electronic inhomogeneity?

Chemical inhomogeneity?

- Fluctuation of Na concentration inherent to the solid-solution.
each Kishimen segment contains a few to several Na ions.
- Why the structure is organized to a certain extent on such a microscopic level??

Length scale by far larger than conventional $\lambda_{TF} (\sim 1 \text{ \AA})$ &
need to introduce very poor screening

Electronic phase separation?

(& the resultant self organization, charge ordering)

- Distinct two regions
- Static, pinned at defect and/or impurity?
- Enhanced by surface effect ?

Bulk phase separation? NMR, x-ray should be done

Summary of STM and Future Target

- Nano-scale electronic inhomogeneity observed in lightly doped $\text{Ca}_{2-x}\text{Na}_x\text{CuO}_2\text{Cl}_2$ single crystals in a form of organized structure
- Likely a kind of electronic phase separation stabilized by impurities and surface?
universal feature of doped strongly correlated insulator

Mn oxide Renner & Aeppli

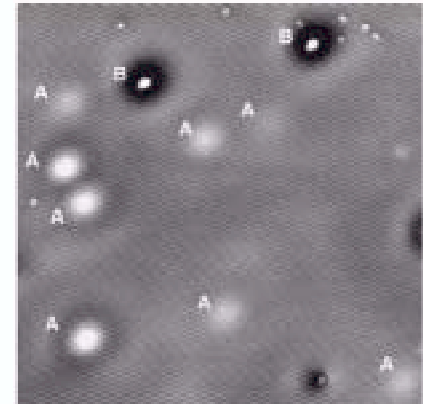
- Future target:
approach dilute and dense carrier concentration limit
likely switches to different physics

dilute limit - individual dopant?

Impurity States,

the same as conventional semiconductor?

how it evolves into the (uniform) dense limit ?



GaAs:Te

*Depuidt, PRB 60
2919 (99)*